

Deciphering Atomic Layer Deposition in Materials Processing: A Surface Science Perspective

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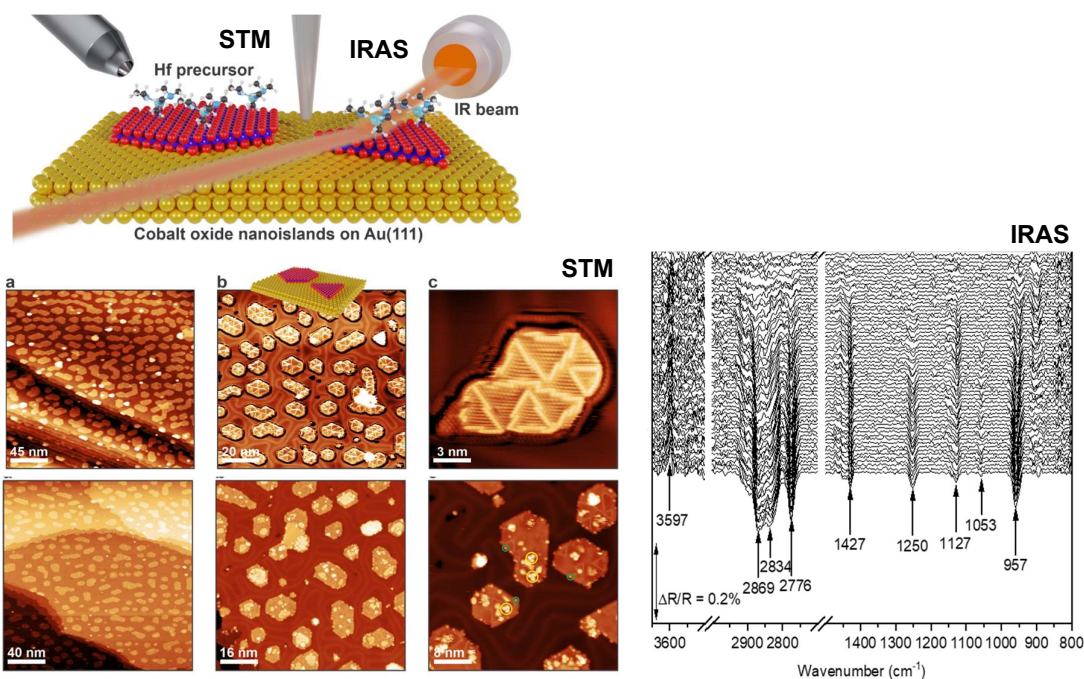


Figure 1: STM and in-situ IRAS recorded during nucleation of TDMAH on CoO_x nanoislands on Au(111). [5]

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